

Docket No. 740107-13

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Patent Application of:

Nobuo SHIMAZU et al.

) Group Art Unit: 2881

Serial No. 09/732,927

Examiner: K. Fernandez

Filed: December 11, 2000

med. December 11, 2000

MANUFACTURING METHOD OF

MASK FOR ELECTRON BEAM

PROXIMITY EXPOSURE AND MASK

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class angenyelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on November 25, 20022.

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K.M. McManus

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SUBMISSION OF SUBSTITUTE DRAWINGS

Commissioner for Patents Washington, D.C. 20231

Sir:

Enclosed please find One (1) sheet (Fig. 1) of formal drawings for review by the Patent and Trademark Office in connection with the above-identified application. Should the enclosed drawing require changes, it is respectfully requested that the Patent and Trademark Office notify the undersigned attorney of same.

Respectfully submitted,

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Dated: November 25, 2002